From traditional photoemission to laser photoemission: disclosing novel phenomena in the time domain at

surfaces and interfaces

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Photoelectric Effect



History



A. Einstein

$$\mathsf{E}_{\mathsf{kin}} \texttt{=} \mathsf{h} \nu \texttt{-} \Phi$$



Ann. d. Phys. 17, 132 (1905): Die kinetische Energie solcher Elektronen ist $\frac{R}{N}\beta v - P.$



Photoelectric effect Einstein, Nobel Prize 1921





History



Precision Method for Obtaining Absolute Values of Atomic Binding Energies

CARL NORDLING, EVELYN SOKOLOWSKI, AND KAI SIEGBAHN Department of Physics, University of Uppsala, Uppsala, Sweden (Received January 10, 1957)

W E have recently developed a precision method of investigating atomic binding energies, which we believe will find application in a variety of problems in atomic and solid state physics. In principle, the method



FIG. 1. Lines resulting from photoelectrons expelled from Cu by Mo $K\alpha_1$ and Mo $K\alpha_2$ x-radiation. The satellites marked D.E.L. are interpreted as due to electrons which have suffered a discrete energy loss when scattered in the source.

Photoemission as an analytical tool Kai Siegbahn, Nobel Prize 1981







Photoemission is one of the most widely employed

experimental techniques

Number of papers published in the last twenty years in peer-review international scientific journals on X-ray Photoelectron Spectroscopy, according to the Thomson Reuters ISI Web of KnowledgeR .







Home > Review of Scientific Instruments > Volume 59, Issue 9 > 10.1063/1.1140055

Published Online: June 1998 Accepted: May 1988

Novel system for picosecond photoemission spectroscopy

Review of Scientific Instruments 59, 1941 (1988); https://doi.org/10.1063/1.1140055

R. Haight, J. A. Silberman, and M. I. Lilie

Femtosecond Laser Interaction with Metallic Tungsten and Nonequilibrium Electron and Lattice Temperatures

J. G. Fujimoto, J. M. Liu, E. P. Ippen, and N. Bloembergen Phys. Rev. Lett. **53**, 1837 – Published 5 November 1984

Time-Resolved Coherent Photoelectron Spectroscopy of Quantized Electronic States on Metal Surfaces

U. Höfer^{*}, I. L. Shumay, Ch. Reuß, U. Thomann, W. Wallauer, Th. Fauster







Three Step Model





1



Laser Photoemission



(a) Step-by-step one-photon process(direct or indirect excitation);



(b) Coherent two-photon or more processes;



T. Fauster, Electromagnetic Waves: Recent Developments in Research 2, 347 (1995).

Our results

 $hv=3.14 eV < \Phi$

(eV)

ENERGY

LECTRON

Non-linear photoemission on Cu (111)



For Coherent two or more photon processes, the energy conservation:

$$E_{K}=n h\nu - |E_{B}| - \Phi$$

Pagliara et al. Surf. Science 2008 Pagliara et al. Surf. Science 2006 Ferrini, ..Pagliara,..PRL 2004 Banfi,...Pagliara,...PRL 2005

0

k₁₁ α₀/π



Transport to the surface

w background

 $E_{\rm kin}$

Inelastic scattering of the excited electrons with:

GENERATION OF SECONDARY ELECTRONS

Other electrons ۲

intensity

Phonons ۲





Mean free path and photoemission probing depth



Electron Kinetic Energy (eV)

- Extreme surface sensitive
- Clean surface and UHV required
- Laser photoemission is more









Energy Conservation $E_{kin} = h\nu - \phi - |E_B|$ Momentum Conservation $\hbar \mathbf{k}_{||} = \hbar \mathbf{K}_{||} = \sqrt{2m E_{kin}} \cdot \sin \vartheta$

A shrinking of momentum space with Laser Photoemission.





Laser ARPES

Comparison of Bi2212 spectra at different photon energies



With Laser

- Superior Momentum Resolution
- Finer Energy Resolution
- Higher quality data in a shorter amount of time

AND INCA SACE

From Dessau Group, Science 310, 1271 (2005)





December, 2017

Time Resolved Laser ARPES

ARPES from a laser excited sample

F. Schmitt et al., Science 321, 1649 (2008)



The pump $h\nu < \Phi$ (1.5 eV - 50fs) The probe $h\nu > \Phi$ (6 eV - 90 fs)



Time Resolved NonLinear Photoemission (TR-NLPE):

- fs relaxation time of excited states; ullet
- charge transfer processes.

 $hv_{PUMP} < \Phi$







Amplified Ti-Sa laser source

Tunability of the pump (0.8 eV to 6.1eV)





TIME-RESOLVED NON-LINEAR PHOTOEMISSION





TOF PARAMETERS : Acceptance Angle : $\pm 0.83^{\circ}$ $\Delta E = 30 \text{meV} @ 2 \text{eV}$



Aims

Our Aims: Investigation of electronic structure and electron dynamics **at the interfaces**

Graphene /metal interface



- Gr/Cu(111);
- Gr/lr(111);
- Gr/Ni(111).





Role of the Substrate Orientation in the Photoinduced Electron Dynamics at the Porphyrin/Ag Interface

Silvia Tognolini[†], Stefano Ponzoni[†], Francesco Sedona[‡], Mauro Sambi[‡], and Stefania Pagliara^{††} [†] I-LAMP and Dipartimento di Matematica e Fisica, Università Cattolica, 25121 Brescia, Italy

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J. Phys. Chem. Lett., 2015, 6 (18), pp 3632–3638 DOI: 10.1021/acs.jpclett.5b01528 Publication Date (Web): August 31, 2015 Copyright © 2015 American Chemical Society

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Abstract







The interaction of molecules with metal substrate is the crucial element in charge injection devices:

1. Molecular electronic energy levels alignment;





The interaction of molecules with metal substrate is the crucial element in charge injection devices:

- 1. Molecular electronic energy levels alignment;
- 2. Electron transfer processes at the interface.







NonLinear photoemission (hv = 3.54 eV < Φ @ k_{//}=0) at TPP/Ag interfaces



HOMO-1 @ 2.3 eV below Fermi level



EXC1: 1° excited state (@ 0.6 eV above the Fermi level)

EXC2: 2° excited state (@ 2.1 eV above the Fermi level)



TPP UV-VIS absorption spectrum



TPP UV-VIS absorption spectrum





The role of the hot electrons is crucial in the indirect charge transfer across the organic - metal /semiconductor interface





C. Frishkorn and M. Wolf, Chem. Rev. 2006



Time Resolved Non Linear Photoemission on TPP/Ag(100) PUMP: hv = 3.14 eV, PROBE: hv = 3.54 eV @ $k_{//}=0$



Time-Resolved NL-PES (PUMP: hv = 3.14 eV, PROBE: hv = 3.54 eV @ $k_{//}=0$) at TPP/Ag(100) interface



- EF coherently photoemitted by 3.14eV+3.54 eV photons;
- EF coherently photoemitted by 3.54 eV+3.54 eV photons;





Time-Resolved NL-PES (PUMP: hv = 3.14 eV, PROBE: hv = 3.54 eV @ $k_{//}=0$) at TPP/Ag interfaces


Time-Resolved NL-PES (PUMP: hv = 3.14 eV, PROBE: hv = 3.54 eV @ $k_{//}=0$) at TPP/Ag interfaces



- The pump pulse excites a hot electrons population in the empty Ag(100) spbands;
- The electrons excited in a state of higher energy relax in the EXC1 in a time of 250 fs and finally they are photoemitted by the probe pulse.



Molecules/metal interface



Aims

Our Aims: Investigation of electronic structure and electron dynamics **at the interfaces**



- Gr/Cu(111);
- Gr/Ir(111);
- Gr/Ni(111).

Molecules /metal interface



- C60/Ag(100);
- TPP/Ag(100) e TPP/Ag(111) ;
- C60/Tpp/Ag(100).

Outlines

What are Interface States?

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.... surface states play a key role in the photo-induced charge transfer processes at the interface



Indirect electron transfer









C. Frishkorn and M. Wolf, Chem. Rev. 2006



Why to study Interface and Image Potential States?









Properties of Image Potential States:

- Localized in the z direction outside the substrate surface
- Electrons are quasi-free in the plane parallel to the sample surface
- Long lifetime
- Interactions may result in a modified IPS electron mass m*



$$E(k_{||}) = E_v - e_n + \hbar^2 k_{||}^2 / 2m ,$$

$$e_n = (1 \text{ Ry}) / 16(n+a)^2, \quad n = 1, 2, 3, \dots$$

$$a = (1 - \Phi_C / \pi) / 2 .$$



Echenique et al., Surface Science Reports 2004 U. Höfer et al., Progresse in Surface Science 80, 49- 91, 2005



PHYSICAL REVIEW B 85, 081402(R) (2012)

Trapping surface electrons on graphene layers and islands

D. Niesner,¹ Th. Fauster,¹ J. I. Dadap,² N. Zaki,² K. R. Knox,² P.-C. Yeh,² R. Bhandari,² R. M. Osgood,² M. Petrović,³ and M. Kralj³



A Surface StateImage Potential States

TABLE I. Experimental and calculated binding energies and lifetimes for image-potential states on graphene/Ir(111).					
n	E_n^{\exp} (eV)	E_n^{calc} (eV)	τ (fs)		
1	0.83 ± 0.02	0.59	35 ± 3		
2	0.19 ± 0.02	0.18	114 ± 6		
3	0.09 ± 0.02	0.08	270 ± 12		

Two Potential Wells

ARE EXPECTED !!

S Pagliara, S Tognolini, L Bignardi, G Galimberti, S Achilli, MI Trioni, WF van Dorp, V Ocelík, P Rudolf, F. Parmigiani, Physical Review B 91 (19), 195440 (2015)

Gr/Cu(111)

- The SS results shifted of about 150 meV
- IPS state preserves the metal character

	SS	IPS (n=1)	QWS
Gr/Cu(111)	BE 0.24±0.05 eV m*/m _e =0.47±0.04	BE= 0.90 \pm 0.05 eV m*/m _e = 0.9 \pm 0.1	BE = $0.45 \pm 0.05 \text{ eV}$ m*/m _e = 1.3 ± 0.1
Cu(III)	BE = 0.39 ±0.05 eV m*/m _e =0.45±0.05	BE= 0.84 \pm 0.03 eV m*/m _e = 1.26 \pm 0.07	

One potential model

Gr/Ni(111)

-

Surface State on Ni(111)

J. Lobo-Checa et al. PRB 77, 075415 (2008)

Unpublished data

	SS	IPS (n=1)	QWS	
Gr/Ni(111)	BE 0.25±0.05 eV m*/m _e = 1.7±0.2	BE= 0.95 \pm 0.05 eV m*/m _e = 1.1 \pm 0.1	BE = $2.05 \pm 0.05 \text{ eV}$ m*/m _e = 0.6 ± 0.1	
Ni(111)		BE= 0.80 \pm 0.03 eV [6] m*/m _e = 1.12 \pm 0.06[6]		
[6] Lobo-Checa et al., Phys. Rev. B 77,(2008).				

[7] S.Schuppler et al., Phys. Rev. B 42,(1990).

Ab initio calculations

Density functional theory (DFT) as implemented in the SIESTA package. To model the Ni(111) surface we used a supercell approach with a thick nickel slab (52 layers).

In the model the image potential is not present.

The electronic structure has been projected on the Ni atoms at the surface.

MIC

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- <u>Molecules /Ag</u>
 (Università di Padova)
 Mauro Sambi
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Collaborations

- Graphene /Cu(111)

Petra Rudolph (Groningen University) Fulvio Parmigiani (Università di Trieste) Luca Bignardi (Trieste Elettra)

- <u>Graphene/Ni(111)</u> Cinzia Cepek (CNR-IOM) Cristina Africh (CNR-IOM)

- <u>Graphene/Ir(111)</u> Carlo Mariani (La Sapienza) Luca Longetti (La Sapienza)

- **Theory group** Mario I. Trioni (ISTM-CNR) Simona Achilli (ISTM-CNR) Elisabetta del Castillo

Thanks for your attention

More details here:

- S Tognolini, S Ponzoni, F Sedona, M Sambi, S Pagliara Role of the Substrate Orientation in the Photoinduced Electron Dynamics at the Porphyrin/Ag Interface The Journal of Physical Chemistry Letters 6 (18), 3632-3638 (2015)
- S Tognolini, S Achilli, L Longetti, E Fava, C Mariani, MI Trioni, S Pagliara Rashba Spin-Orbit Coupling in Image Potential States Physical Review Letters 115 (4), 046801 (2015)
- S Pagliara, S Tognolini, L Bignardi, G Galimberti, S Achilli, MI Trioni, WF van Dorp, V Ocelík, P Rudolf, F Parmigiani Nature of the surface states at the single-layer graphene/Cu (111) and graphene/polycrystalline-Cu interfaces Physical Review B 91 (19), 195440 (2015)

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 S Tognolini, S Pagliara, L Bignardi, S Ponzoni, P Rudolf, F Parmigiani Surface states resonances at the single-layer graphene/Cu (111) interface Surface Science 643, 210-213 (2016)

Thanks for your attention

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E. V. Chulkov et al., Surf. Sci. 437, 330 (1999).

Graphene potential

H. G. Zhang, J. Phys.: Condens. Matter 22, 399802 (2010).

Graphene was grown on a Cu(111) single crystal (MaTeck GmbH) that was previously Ar-sputtered (1 keV) and annealed (650 K) in ultrahigh vacuum. The crystal was then transferred (through air) into a vacuum furnace (base pressure 10^{-5} mbar), where it was reduced in a mixture of 0.5 mbar of hydrogen (Messer, purity 5.0) and 0.1 mbar of argon (Linde, purity 5.0) for 4 h at a temperature of 1250 K before graphene was grown by exposure to a mixture of argon (0.1 mbar), hydrogen (0.5 mbar), and methane (0.5 mbar, Messer, purity 4.0) for two min at 1250 K. The sample was subsequently cooled to room temperature in an argon flow (0.09 mbar) at a rate of 15 K/min. The Cu foil (thickness 25 µm, 99.999% purity, ESPI Metals) was preetched in a 0.25 M solution of H₂SO₄ in water for 5 min, rinsed in water and ethanol, dried in an argon flow and transferred to the vacuum furnace. The foil was then reduced in H₂ and Ar for 1 hr. at the same temperature and pressure employed for Cu(111), while the growth of graphene followed the same protocol described above for the growth on Cu(111).

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All the calculations of the electronic structures were carried out within the density functional theory (DFT) as implemented in the SIESTA package. Within this code, linear combinations of pseudo-atomic orbitals are used to solve the Kohn-Sham equations with 3D periodic boundary conditions. The exchange-correlation energy and electron-ion interaction were described by the Perdew-Burke-Ernzerhof generalized gradient approximation and norm-conserving pseudopotentials in the fully nonlocal form, respectively.

To test our computational setup (basis set, pseudopotential, etc.) we calculated the lattice constant of the Ni bulk and we obtained a value of 3.56 Ang, being the experimental one equal to 3.52 Ang. To model the Ni(111) surface we used a supercell approach with a thick nickel slab (52 layers).

In order to avoid spurious interactions we separated periodic replicas of nickel slabs with an appropriate vacuum region.

The optimized geometry was obtained relaxing the two upper layers until the residual forces were smaller than 0.01~eV/Ang.

In Situ Observations of the Atomistic Mechanisms of Ni Catalyzed Low Temperature Graphene Growth

Laerte L. Patera,^{†, ‡} Cristina Africh,^{†, *} Robert S. Weatherup,[§] Raoul Blume,[⊥] Sunil Bhardwaj,[∥] Carla Castellarin-Cudia,[†] Axel Knop-Gericke,[#] Robert Schloegl,[#] Giovanni Comelli,^{†, ‡} Stephan Hofmann,^{§, *} and Cinzia Cepek[†] Epitaxial graphene on Ni(111) surface. No trace of carbide is present.

Gr /Ni(111)

Gr/Ni(111)

- Grown by CVD , hydrocarbon precursor, 400°C<T<500°C

Spin-orbit interaction from solid state course

RASHBA EFFECT

The magnetic field is due to the electron moving in the electric field at the surface





$$\Delta E = -\boldsymbol{\mu}_s \cdot \boldsymbol{B}_l$$



M. Weinelt & coworkers, PRL 95, 107402 (2005)

Example: 3ML Fe film on Cu(100)







Thanks!!!







Gr /Ni(111)



Photoemission intensity:









Graphene/metal interface

Graphene-Ir(111) distance > 3 Å









Surface State with a giant Rashba splitting

$$E_{\pm}(\mathbf{k}_{\parallel}) = \frac{\hbar^2 \mathbf{k}_{\parallel}^2}{2m^*} \pm \alpha_R |\mathbf{k}_{\parallel}|,$$







 \sim

Is the Image State Rashba splitted??





S. Tognolini, S. Achilli, L. Longetti, E. Fava, C. Mariani, M. I. Trioni, and S. Pagliara Phys. Rev. Lett. 115, 046801 (2015)

Graphene/metal interface





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Graphene/metal interface

Derivative of the atomic

WHY?

potential

$$\alpha_R = 2/c^2 \int |\psi(z)|^2 \partial_z V dz,$$

The Rashba parameter depends on the amplitude of the wave function at the surface and on its decay into the substrate!

Charge distribution of the surface state

- J. R. McLaughlan, E. M. Llewellyn-Samuel, and S. Crampin, J. Phys. Condens. Matter 16, 6841 (2004)

- T. Nakazawa, N. Takagi, M. Kawai, H. Ishida, and R. Arafune, Phys. Rev. B 94, 115412 (2016).



